

Low Noise Compact CCD Spectrometer

SM245



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Wide Spectral Range (up to 200~1050nm)

Enhanced Dark Current Noise

High Speed Data Acquisition

Compact & Modular Design



The choice for high speed data acquisition Applications

Spectral Products is offering the new SM245 high speed 2048-pixel array CCD spectrometer. Thanks to the enhanced design on the electronic board of the SM245, the dark current noise level as well as the data acquisition speed have been improved.

Based on special optical bench design, it supports various applications where spectral or color measurements are required, including high speed data acquisition. The SM245 can accept light directly through its built-in slit or via optical fiber. The durable mechanical housing that encloses the SM245 provides stable optical bench operation over a wide range of temperatures.

Our array detectors (in conjunction with our special UV coating process and customized order sorting filters) allows up to an 850nm measurement window from 200nm to 1050nm (smaller measurement window sizes increase spectral resolution and light sensitivity).

Standard interface of the SM245 series is a USB 1.1/2.0 compatible interface with 16-bit AD conversion. Our USB board can support multichannel configuration up to 8. With this multichannel configuration, a high resolution for wide range or a dual spectrometer system (one for measurement and the other for reference) is possible. We apply new UV enhancing coating on the CCD to increase the UV sensitivity below 450nm comparing with the conventional UV coating that is widely used in CCD spectrometers. By the help of this new UV coating, the signal sensitivity below 450nm can get improved 2~3 times more in general.

Software support includes an SDK and DLLs for dedicated applications development and Windows OS-based spectral acquisition and analysis software (SM32ProMX).

Specifications :

Physical Dimension	
Dimensions (mm)	3.54 x 2.76 x 1.73 inches (90 X 70 X 44)
Weight (kg)	0.88lbs (0.4kg)
Fiber Optic Connector	SMA905 N.A.=0.22 Optical Fiber Input
Detector	
Detector	Sony ILX511 (UV Enhanced Coated)
Cooling	None
Windows Material	Quartz or Glass
Spectral Response Range	200-1050 nm
Pixels	2048 (Effective)
Pixel Size	14 μm X 200 μm
Well Depth	62,500 e-
Optical Specification	
Wavelength Range	Full Range : 200-1050 nm
	UV Range : 200-450 nm
	VIS Range : 380-760 nm
	NIR Range : 550-1050 nm
	Other user customized range is possible
Optical Resolution	0.3-10 nm , dependent on spectral range, slit width, and fiber core diameter
Dark Noise RMS	< 35 in 16bit @ 35ms integration time
Signal to Noise Ratio (SNR)	> 300 : 1
Stray Light	<0.1 % AVG.
Filter	Second Order Blocking Filter Installed
Electrical Specification	
ADC resolution	16bit (0~65535)
Minimum Integration Time	1 msec
Computer Interface	USB 1.1/2.0 Compatible
Trigger Mode	Free Run Mode
	Software Trigger Mode
	External trigger mode (9-pin connector) : TTL Edge trigger input/digital output for monitoring
Computer	
Operating System	Windows XP/Windows VISTA/Win 7/Win 8.1/Windows10 (32/64 bit)
Software	SM32ProMX
Software Development Kit	Visual C++ DLL /LabVIEW VI SDK

Applications

Spectrometer SM245

Multichannel Optical Monitoring and Diagnostics of Plasma

- Real time optical monitoring and diagnostics of plasma process in semiconductor fabrications
- Multichannel based OES (optical emission spectroscopy) sensors in plasma process diagnostics

1. Viewport Mount
- Mounted on Process Chamber viewport

2. Optical Fiber and OES Sensor

3. Controller
- Controller configuration for IP information and network (FDC)
- Customized Spectral Calculation Data

Statistical Analysis
Spectrum Database [FDC]

EPD of Etch & Cleaning
- Optimal End Point Detection in Etch and Chamber Cleaning Processes

Leak Detection
- Real-time monitoring and detection of leakage caused by outside air inflow

Process Condition Monitoring
- Real-time process gas behavior and process status monitoring as process conditions change

Plasma Information
- Automatic Measurement of Spatial Uniformity with Plasma Key Factors (PI)

EPD of Etch & Chamber Cleaning

- End Point Detection of plasma etch and cleaning process in semiconductor fabrications
- Saving production cost and time loss by optimization of EPD with statistical algorithms

SF₆/O₂ Mixture plasma
Intensity vs Wavelength (nm) graph showing peaks for F, SiF, and SF.

Etch Depth: 100nm
Intensity vs Elapsed Time (sec) graph showing E T C H and By-Product: SiF.

RF ON / TIME / RF OFF
SIGNAL INTENSITY vs TIME graph showing START OF ETCH, FILM CLEARS, ETCHANT, SUBSTRATE PRODUCT, and FILM PRODUCT.

Fig. 3. Time trace data of (a) process gas species and (b) by-product species.
Intensity (A.U.) vs Time (sec) graphs for SF₆, O₂, SiF, and SiF₄.

Fig. 4. Generated end-point detection signals; tp (process gas species) and tb (by-product).
Intensity (A.U.) vs Time (sec) graph showing End-point detection in Generated tp and tb signal.

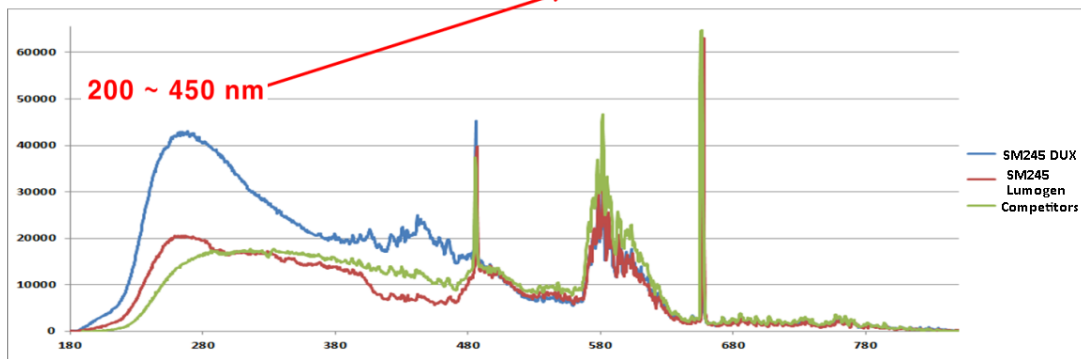
Ultra thin layer of SiO₂
Diagram showing F+ ions, SF₆ plasma, SiF₄, Mask, and Si.

Sang Jeen Hong et. al. (2013)

Highly Deep UV Enhanced Coated CCD

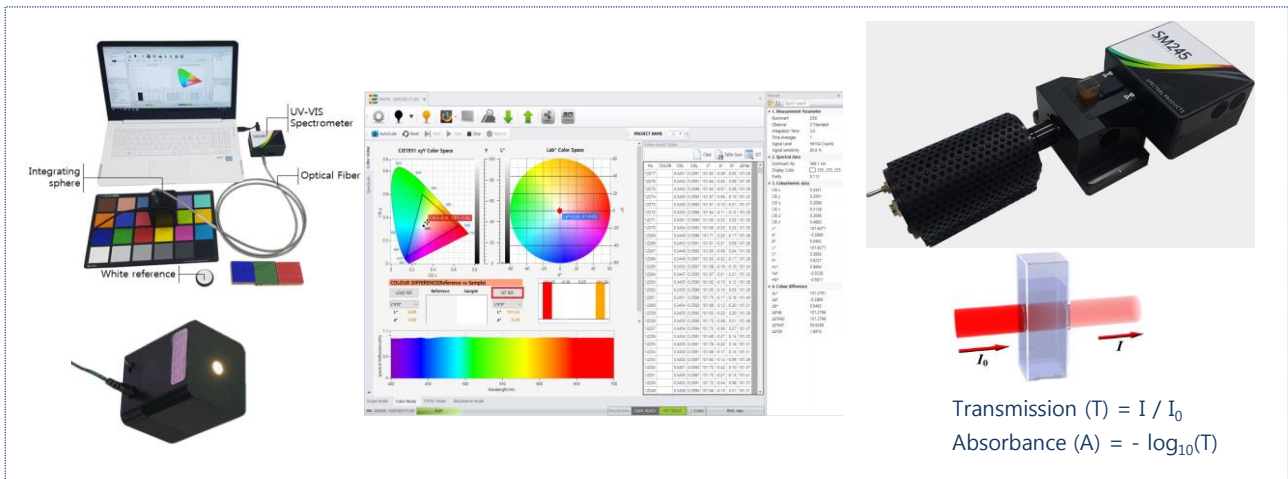
- Responsivity to high deep UV (200-450 nm) is 2-3 times higher than general UV enhanced spectrometers
- Signal to noise ratio (SNR) more accurate when UV spectrum measurement results are acquired

Main peak of Si / N2 / OH / CCL / SiCl etc



Compact Color and Absorbance Measurement System (COLMAN)

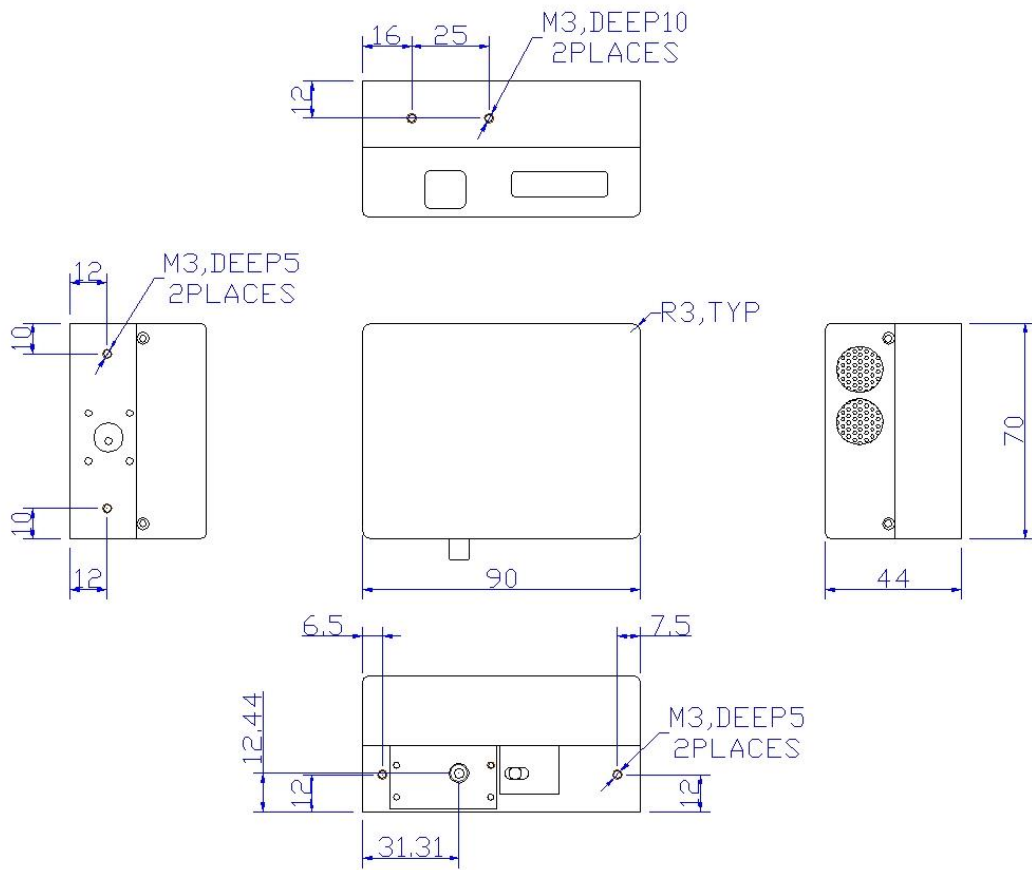
- Reflectance and transmittance mode can provide color measurement using photometric and radiometric values
- Compact spectrophotometer for real time analysis of chemical and optical properties of samples



The COLMAN system includes an Integrating sphere, White reference, UV-VIS Spectrometer, and Optical Fiber. The software interface displays color space plots (CIE 1931, CIE 1964) and a list of colorimetric data. A diagram illustrates the transmission measurement setup, showing incident light I_0 and transmitted light I through a sample.

Transmission (T) = I / I_0
 Absorbance (A) = $-\log_{10}(T)$

Case Dimension :



Units in mm

Ordering Information : Please indicate product number plus description when ordering
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